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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
09/396,582	09/15/1999	HIDEKI KOMATSUDA	105203	7643
25944	7590	05/28/2004		
OLIFF & BERRIDGE, PLC P.O. BOX 19928 ALEXANDRIA, VA 22320			EXAMINER	CHURCH, CRAIG E
			ART UNIT	PAPER NUMBER
			2882	

DATE MAILED: 05/28/2004

Please find below and/or attached an Office communication concerning this application or proceeding.

Offic Action Summary	Application N	Applicant(s)
	09/396582	Komatsuda et al
	Examiner	Art Unit
	Craig E. Church	2882

-- The MAILING DATE of this communication appears on the cover sheet with the correspondence address --

Period for Reply

A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) FROM THE MAILING DATE OF THIS COMMUNICATION.

- Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication.
- If the period for reply specified above is less than thirty (30) days, a reply within the statutory minimum of thirty (30) days will be considered timely.
- If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.
- Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).

Status

- Responsive to communication(s) filed on 3/2/04.
- This action is FINAL. This action is non-final.
- Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under *Ex parte Quayle*, 1935 C.D. 11, 453 O.G. 213.

Disposition of Claims

- Claim(s) 2,3,14,15,21-25,34,51-83 is/are pending in the application.
- Of the above claim(s) _____ is/are withdrawn from consideration.
- Claim(s) 2,3,14,15,21-25,34 is/are allowed.
- Claim(s) 51-83 is/are rejected.
- Claim(s) _____ is/are objected to.
- Claim(s) _____ are subject to restriction and/or election requirement.

Application Papers

- The specification is objected to by the Examiner.
- The drawing(s) filed on _____ is/are: a) accepted or b) objected to by the Examiner.
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).
- The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.

Priority under 35 U.S.C. § 119

- Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).
a) All b) Some * c) None of:
 - Certified copies of the priority documents have been received.
 - Certified copies of the priority documents have been received in Application No. _____.
 - Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).

* See the attached detailed Office action for a list of the certified copies not received.

Attachment(s)

- Notice of References Cited (PTO-892)
- Notice of Draftsperson's Patent Drawing Review (PTO-948)
- Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08)
Paper No(s)/Mail Date _____
- Interview Summary (PTO-413)
Paper No(s)/Mail Date _____
- Notice of Informal Patent Application (PTO-152)
- Other: _____

Claims 62, 70, 76 and 83 are rejected under 35 U.S.C. 112, second paragraph, as being indefinite for failing to particularly point out and distinctly claim the subject matter which applicant regards as the invention. Method claims 62, 70, 76 and 83 improperly depends from apparatus claims.

The following is a quotation of the first paragraph of 35 U.S.C. 112:

The specification shall contain a written description of the invention, and of the manner and process of making and using it, in such full, clear, concise, and exact terms as to enable any person skilled in the art to which it pertains, or with which it is most nearly connected, to make and use the same and shall set forth the best mode contemplated by the inventor of carrying out his invention.

The specification is objected to under 35 U.S.C. 112 first paragraph as failing to support the invention as it is now claimed. As described in the specification, the photoelectric effect is wavelength sensitive and occurs only over a specific range of wavelengths that does not include light. The disclosure explicitly teaches the x-ray range of 5-20 nm (lines 12-13 of page 8) but fails to teach how to practice the invention for light as now claimed.

Claims 51-83 are rejected under 35 U.S.C. 112 first paragraph for the reasons set forth in the objection to the specification.

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negated by the manner in which the invention was made.

Claims 51-62 are rejected under 35 U.S.C. 103(a) as being unpatentable over Japanese patent 5-288696 in view of Miyake et al (6504896). The Japanese patent teaches an x-ray lithography apparatus comprising synchrotron x-ray source 50, x-ray mirror 2 whose reflective surface may become dirty and means 10 for measuring the flow of photoelectrons released by the mirror surface as an indication of accumulated dirt. The Japanese patent does not illustrate a complete lithography system, and it would have been obvious to employ its dirt sensing means to monitor one or more optical surfaces in any common lithograph (since that is its function) such as that taught by Miyake which includes x-ray source 1, integrator 5, mask 7, projection system 8 and wafer 9.

Claims 2, 3, 14, 15, 21-25 and 34 are allowed.

Applicant's arguments filed March 2, 2004 have been fully considered but they are not persuasive. Claims 51-62 recite measuring the photoelectric current in optical members as taught by the Japanese reference but do not recite calculating or control means responsive thereto as argued.

THIS ACTION IS MADE FINAL. Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the mailing date of this final action.

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Art Unit: 2882

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Any inquiry concerning this communication should be directed to Craig E. Church at telephone number 703-308-4861.

Craig E. Church

**Craig E. Church
Senior Examiner
Art Unit 2882**